## **AMENDMENTS TO THE CLAIMS:**

This listing of claims will replace all prior versions, and listings, of claims in the application:

## LISTING OF CLAIMS:

:

1. (Currently Amended) A slurry for cutting a silicon ingot, comprising abrasive grains and a basic material, characterized in that wherein:

the basic material is alkaline metal hydroxide, alkaline earth hydroxide or mixtures thereof;

a content of the basic material is at least 3.5% by mass based on a total mass of a liquid component of the slurry;

the slurry contains organic amine in a mass ratio of 0.5 to 5.0 with respect to water in the liquid component of the slurry; and

pH of the slurry is 12 or more.

2. (Currently Amended) A method of cutting a silicon ingot using a slurry for cutting a silicon ingot, comprising abrasive grains and a basic material, characterized in that wherein:

the basic material is alkaline metal hydroxide, alkaline earth hydroxide or mixtures thereof;

a content of the basic material is at least 3.5% by mass based on a total mass of a liquid component of the slurry;

the slurry contains organic amine in a mass ratio of 0.5 to 5.0 with respect to water in the liquid component of the slurry;

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pH of the slurry is 12 or more; and the slurry is used at 65°C to 95°C.